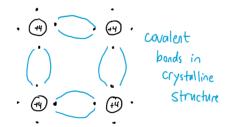
Photovoltaics

Tuesday, February 13, 2024

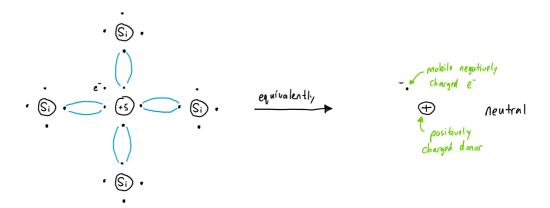
3:57 PM

Photovultaic Material/Device

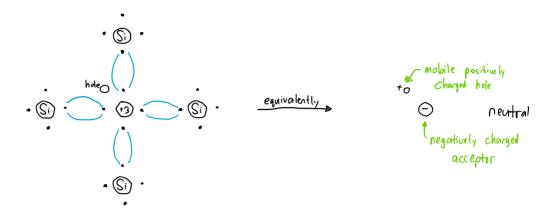
- · A material/device that can convert energy in photons of light into electrical energy
- · PV commercialization has been impacted by cost in the past. But now installed cost \$1/W (for utility-scaled solar PV)
- · Shockley-Queisser Limit (1961)
 - Theoretical limit of power efficiency for single p-n junction $\frac{\sim 33\%}{\sim 33\%}$ (can do better with more layers)
- * PV devices use Semiconductors, mainly Si
 - · Si atom has 14 protons, 14 electrons (of which 4 are valence electrons)
 - · A Common representation:



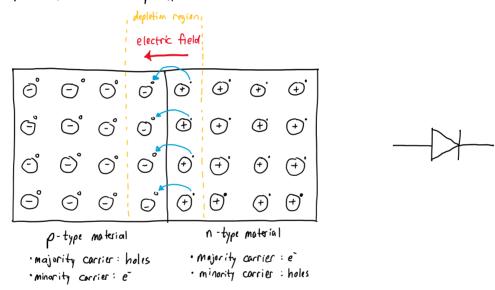
· n-type material : doped with a pentavalent donor (e.g. P, As)



op-type material: doped with trivalent acceptors (e.g. B, Ga)



· Create p-n junction w/ p-type and n-type materials

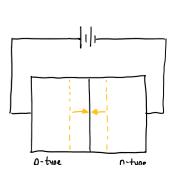


- · e/hole recombinations in the depletion region
- · Create internal electric field
- * electric field stops further diffusion

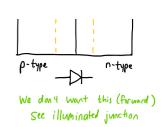
 L. Stop flow of majority corriers across junction

· 2 types of currents in p-n junction 1) diffusion current

- · majority carrier (e) on n-side cross into p-side
- · In forward bios, barries is lower and more et diffuse



· In forward bios, barries is lower and more e diffuse



2) drift current

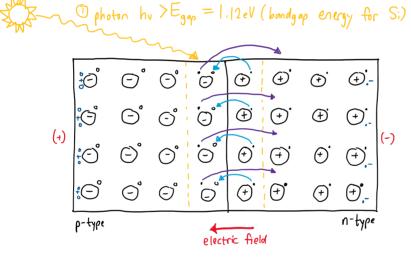
- minority carriers (e) on p-side "wander" into transition region
- ·small because there are few minority carriers

GOAL: Optical excitation of EHPs near the junction

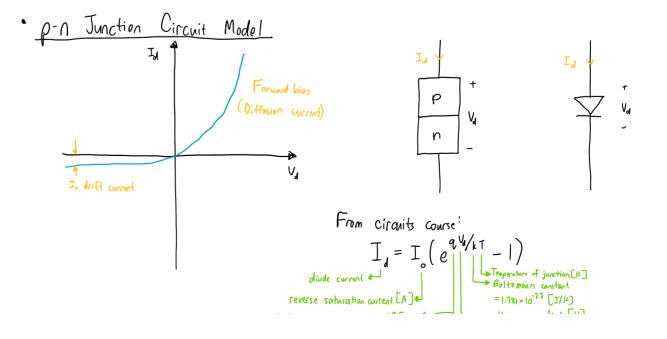
* Want drift current

· Illuminated Junctions

- · Forward bias is not an option (want PV to generate)
- · Need optical excitation near the junction to provide drift "generation" current



- ② e swept across due to internal electric field → drift current
- 3 accumulate et on noside, holes on poside
- 4 Drift current creates voltage



· Increase "drift" or "generation" current by optical excitation

